Application No.: 10/614,451 Docket No.: 07200/032001

## **AMENDMENTS TO THE CLAIMS**

Please amend the claims as follows:

- 1. (Currently Amended) A resist stripping equipment, comprising:
  - a first stripping solution tank in which resist stripping solution is preserved;
  - a first resist stripping chamber in which a substrate covered with resist is accommodated;
  - a <u>first</u> spray which is connected to the <u>first</u> stripping solution tank and sprays the resist stripping solution into the resist in the <u>first</u> resist stripping chamber;
  - a <u>first</u> solution line which supplies the sprayed resist stripping solution from the <u>first</u> resist stripping chamber to the <u>first</u> resist stripping tank;
  - a gas line which supplies a mixed gas containing a resist stripping solution component from the <u>first</u> resist stripping <del>container</del> <u>chamber</u> to outside;
  - a gas/liquid separation block which is connected to the gas line, and which separates the resist stripping solution component from the introduced mixed gas; and
  - a second resist stripping chamber which is connected to the first resist stripping chamber and whereto the substrate is supplied from the first resist stripping chamber;
  - a second stripping solution tank in which resist stripping solution is preserved;
  - a second spray which is connected to the second stripping solution tank and sprays the resist stripping solution into the resist in the second resist stripping chamber;
  - a second solution line which supplies the sprayed resist stripping solution from the second resist stripping chamber to the second resist stripping tank;
  - a recovered resist stripping solution line which is connected to the gas/liquid separation block and supplies the separated resist stripping solution component to the <u>second</u> stripping solution tank; and
  - a line which is connected to the second stripping solution tank and supplies the resist stripping solution to the first stripping solution tank.

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- 2. (Currently Amended) The resist stripping equipment of claim 1, further comprising:
  - a separated gas supply unit which receives gas separated from the resist stripping solution component in the liquid/gas separation block and supplies the gas to the a gas spout unit,

wherein at least one of the resist stripping chambers includes a the gas spout unit.

- (Original) The resist stripping equipment of claim 2, wherein the gas spout unit is disposed facing the substrate.
- 4. (Currently Amended) The resist stripping equipment of claim 1, further comprising: an inert gas supply unit which is connected to the resist stripping chambers and supplies inert gas into the resist stripping chambers.
- 5. (Currently Amended) The resist stripping equipment of claim 4, <u>further comprising</u>:
  - a plurality of the resist stripping chambers provided in multiple stages to communicate with each other;
  - a rinse chamber provided to communicate with one of the plurality of resist stripping chambers at a last stage, the rinse chamber being supplied with water;
  - the gas/liquid separation block connected to one of the <del>plurality of resist stripping chambers at a first stage; and</del>
  - the inert gas supply unit connected to the rinse chamber,
  - wherein the resist stripping solution is a water-based resist solution.
- 6. (Currently Amended) The resist stripping equipment of claim 4, further comprising:
  - a plurality of the resist stripping chambers provided in multiple stages to communicate with each other;
  - a rinse chamber provided to communicate with one of the <del>plurality of</del> resist stripping chambers at a last stage, the rinse chamber being supplied with water;
  - the gas/liquid separation block connected to one of the <del>plurality of</del> resist stripping chambers at a first stage; and
  - the inert gas supply unit connected to one of the <del>plurality of</del> resist stripping chambers at the last stage,
  - wherein the resist stripping solution is a non-water-based stripping solution.

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